

Device Modeling Report

COMPONENTS: Power MOSFET (Professional)
PART NUMBER: 2SK3994
MANUFACTURER: TOSHIBA
Body Diode (Professional) / ESD Protection Diode

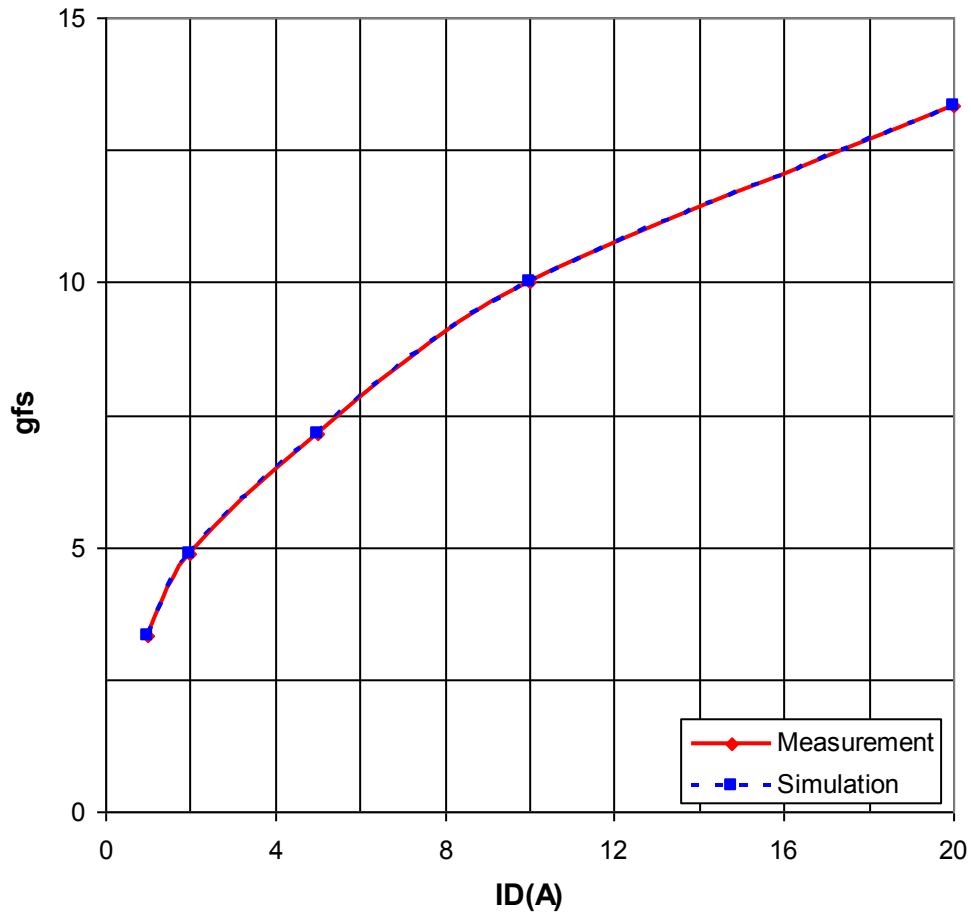


MOSFET MODEL

PSpice model parameter	Model description
LEVEL	
L	Channel Length
W	Channel Width
KP	Transconductance
RS	Source Ohmic Resistance
RD	Ohmic Drain Resistance
VTO	Zero-bias Threshold Voltage
RDS	Drain-Source Shunt Resistance
TOX	Gate Oxide Thickness
CGSO	Zero-bias Gate-Source Capacitance
CGDO	Zero-bias Gate-Drain Capacitance
CBD	Zero-bias Bulk-Drain Junction Capacitance
MJ	Bulk Junction Grading Coefficient
PB	Bulk Junction Potential
FC	Bulk Junction Forward-bias Capacitance Coefficient
RG	Gate Ohmic Resistance
IS	Bulk Junction Saturation Current
N	Bulk Junction Emission Coefficient
RB	Bulk Series Resistance
PHI	Surface Inversion Potential
GAMMA	Body-effect Parameter
DELTA	Width effect on Threshold Voltage
ETA	Static Feedback on Threshold Voltage
THETA	Mobility Modulation
KAPPA	Saturation Field Factor
VMAX	Maximum Drift Velocity of Carriers
XJ	Metallurgical Junction Depth
UO	Surface Mobility

Transconductance Characteristic

Circuit Simulation Result

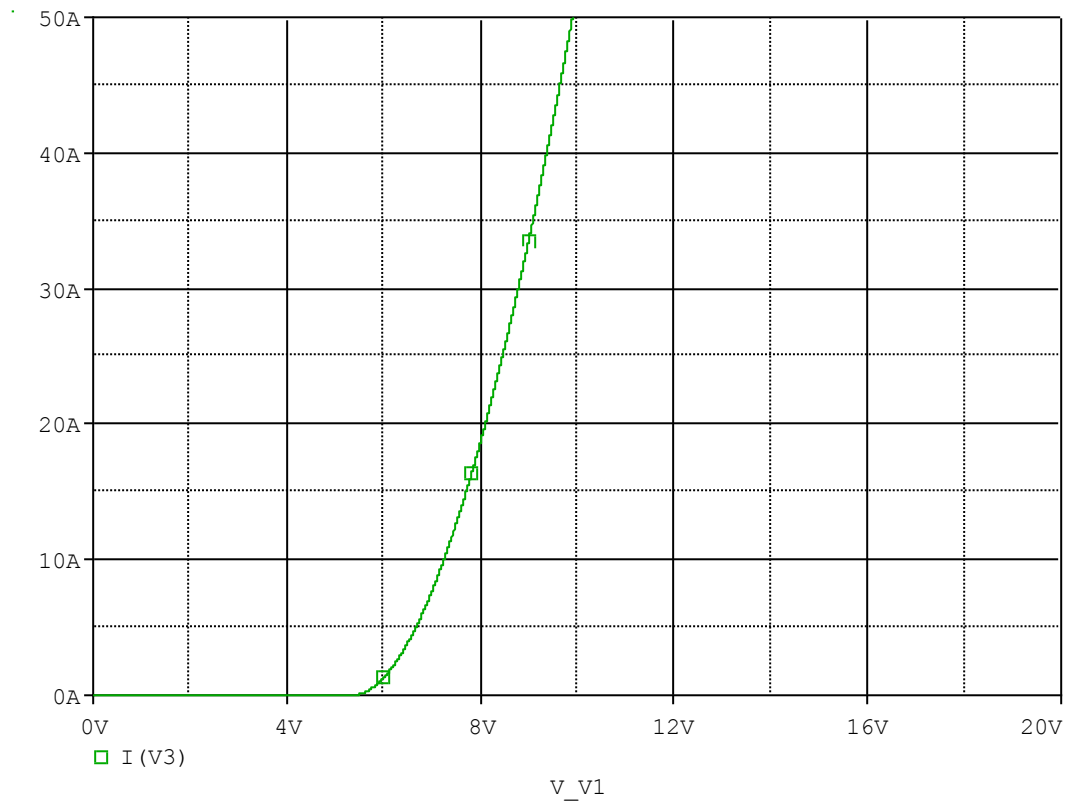


Comparison table

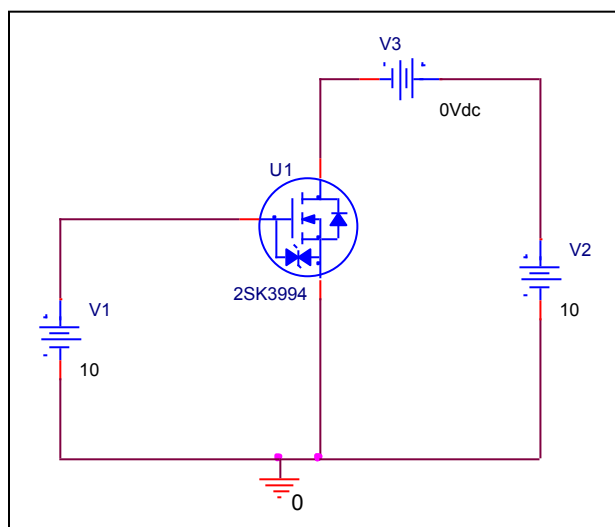
Id(A)	gfs		Error (%)
	Measurement	Simulation	
1	3.333	3.448	3.450
2	4.878	4.808	-1.435
5	7.143	7.386	3.402
10	10.000	10.132	1.320
20	13.333	13.727	2.955

V_{gs}-I_d Characteristic

Circuit Simulation result

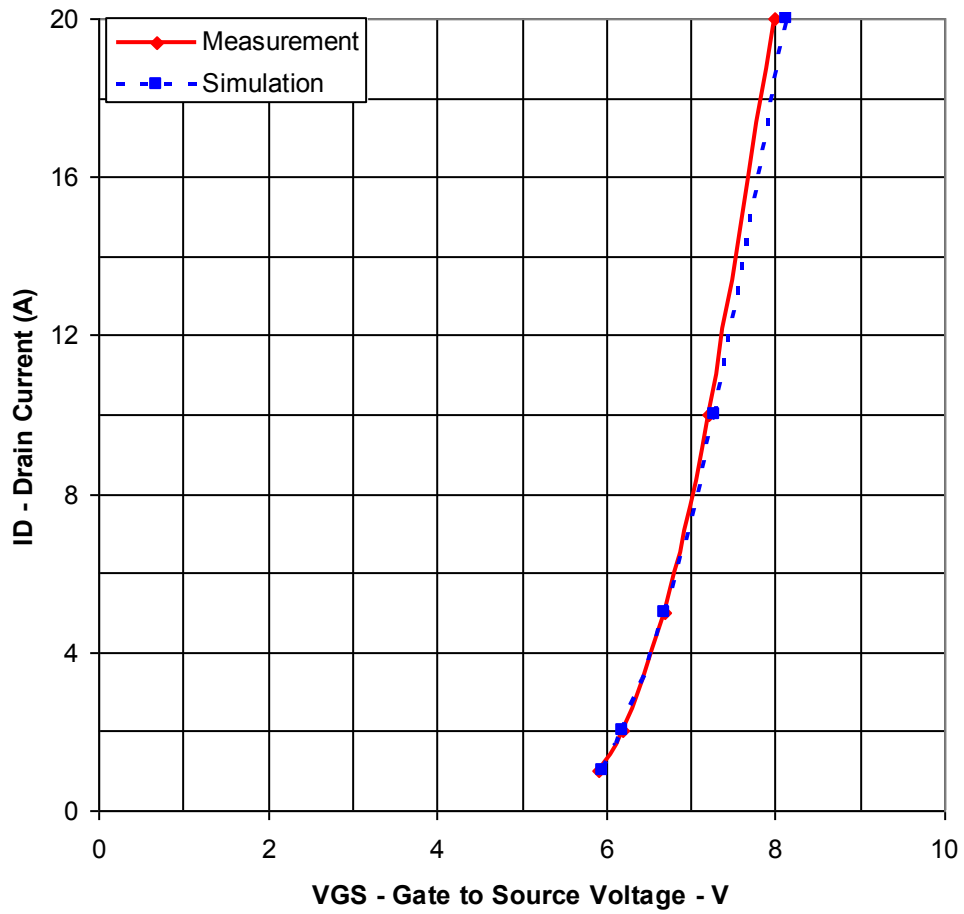


Evaluation circuit



Comparison Graph

Circuit Simulation Result

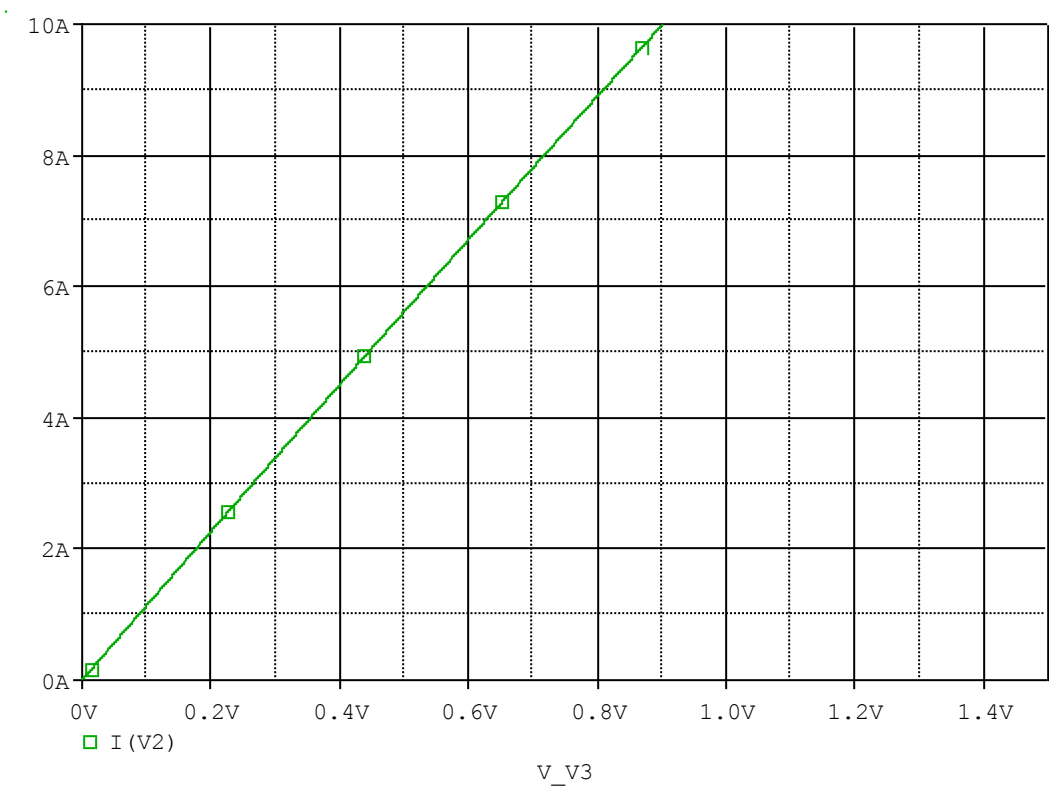


Simulation Result

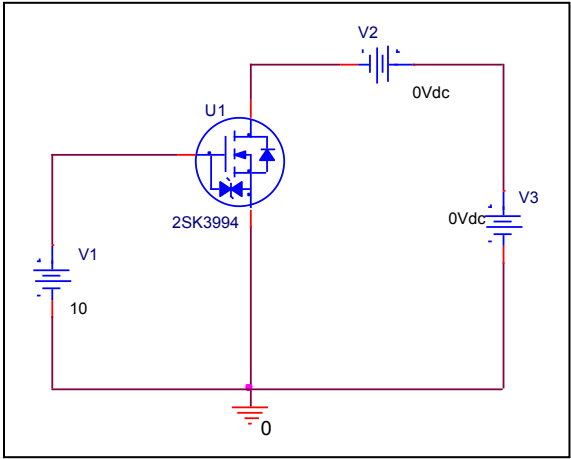
I_D (A)	V_{GS} (V)		Error (%)
	Measurement	Simulation	
1	5.9	5.9176	0.298
2	6.2	6.1651	-0.563
5	6.7	6.6667	-0.497
10	7.2	7.2491	0.682
20	8	8.1034	1.293

Rds(on) Characteristic

Circuit Simulation result



Evaluation circuit

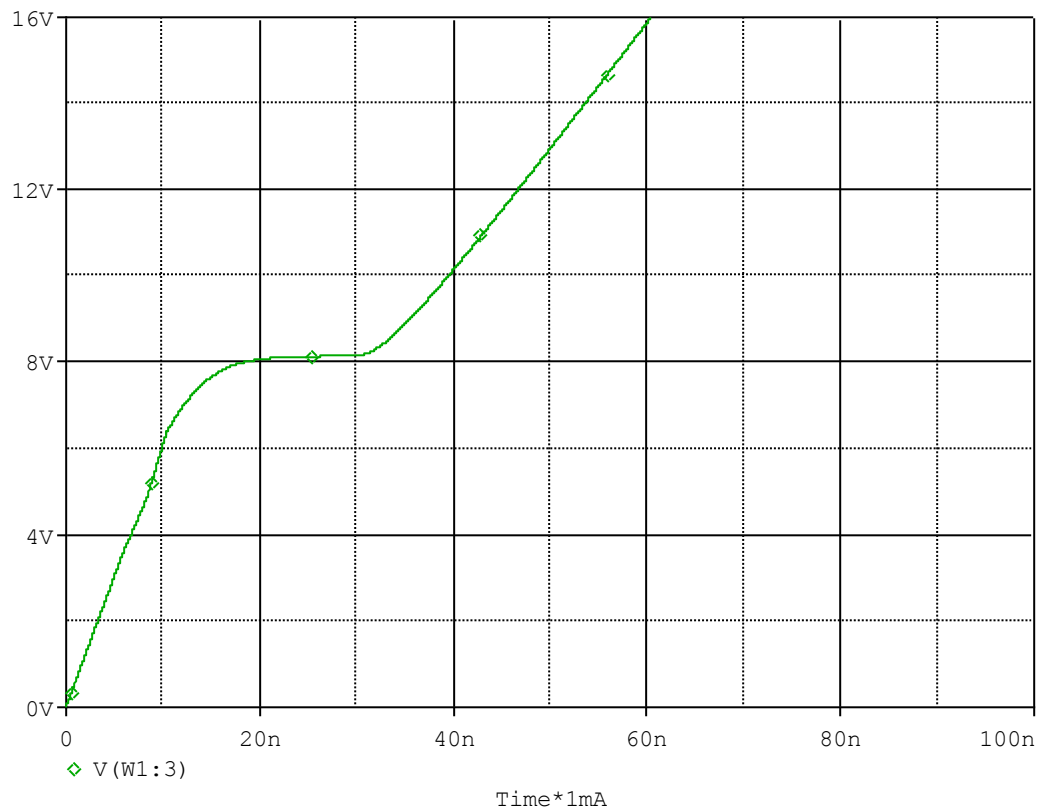


Simulation Result

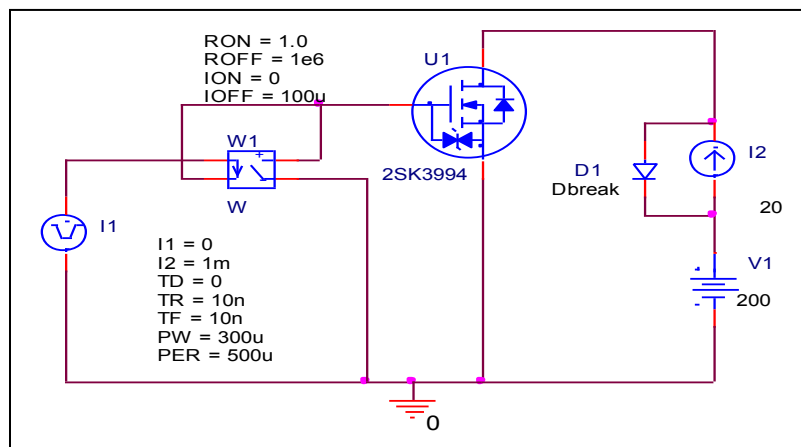
$I_D=10A, V_{GS}=10V$	Measurement		Simulation		Error (%)
$R_{DS(on)}$	90	mΩ	90.2	mΩ	0.222

Gate Charge Characteristic

Circuit Simulation result



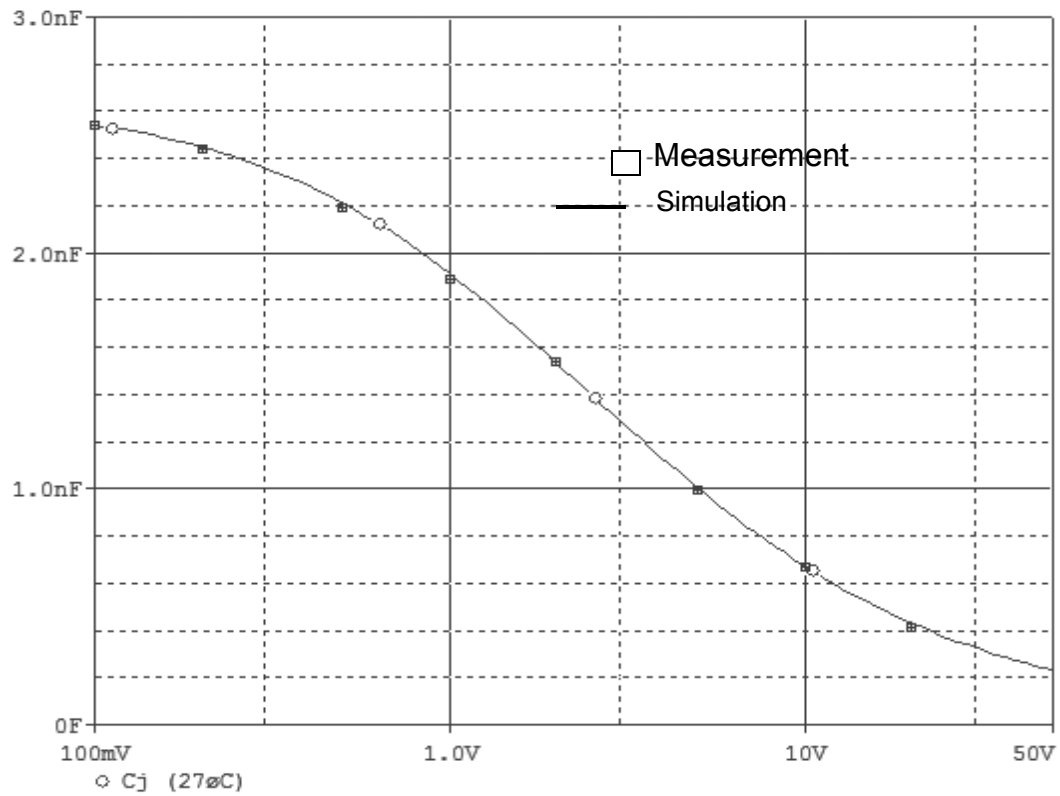
Evaluation circuit



Simulation Result

$V_{DD}=200V, I_D=20A$	Measurement		Simulation		Error (%)
Qgs	11	nC	11.009	nC	0.082
Qgd	20	nC	20.392	nC	1.960
Qg	40	nC	40.513	nC	1.283

Capacitance Characteristic

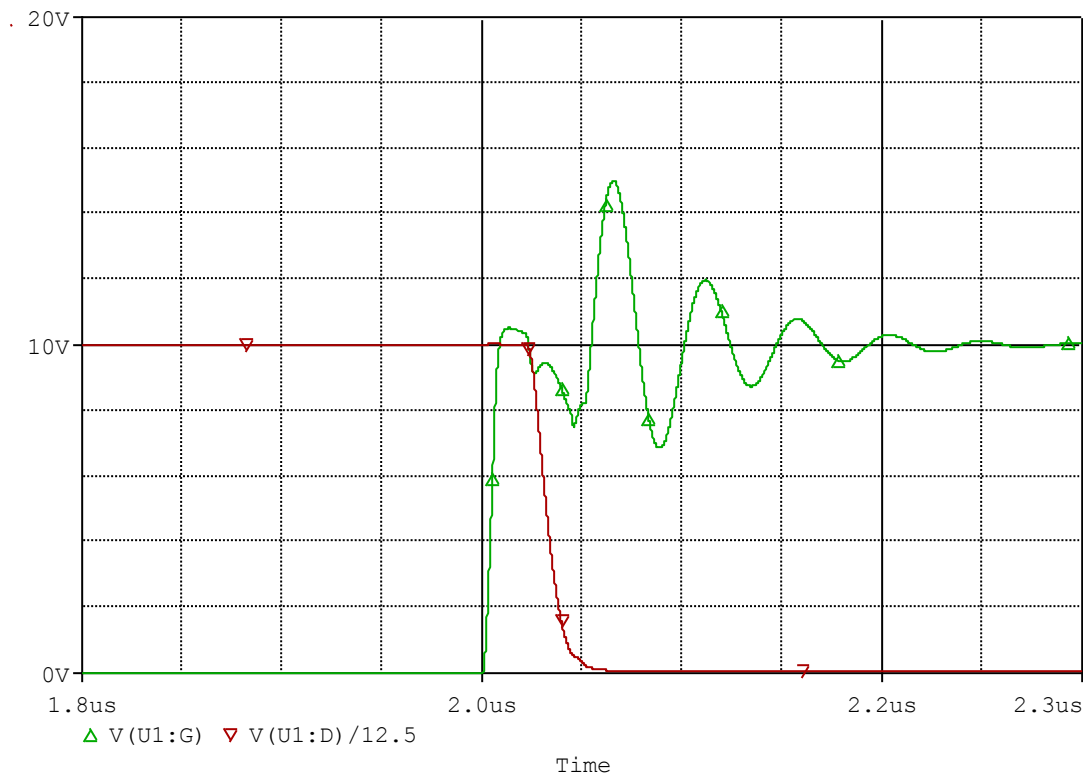


Simulation Result

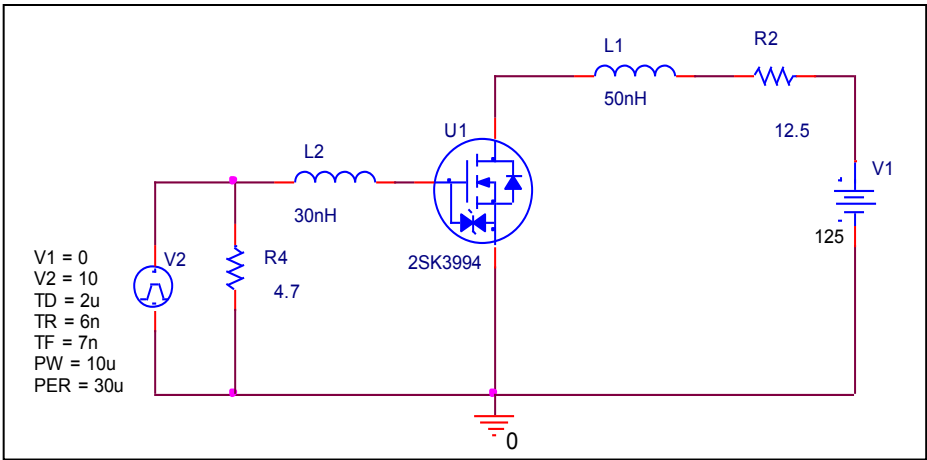
V _{DS} (V)	Cbd(pF)		Error(%)
	Measurement	Simulation	
0.1	2550	2500	-1.961
0.2	2450	2449	-0.041
0.5	2200	2210	0.455
1	1900	1915	0.789
2	1550	1530	-1.290
5	1000	1005	0.500
10	680	670	-1.471
20	420	430	2.381

Switching Time Characteristic

Circuit Simulation result



Evaluation circuit

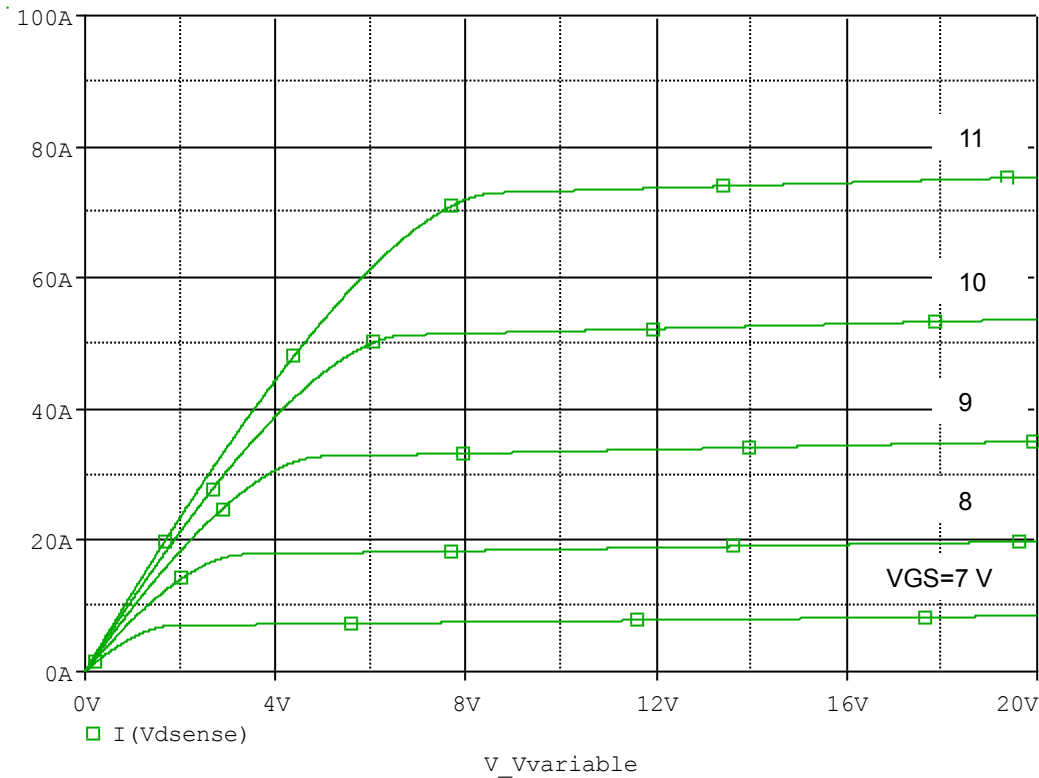


Simulation Result

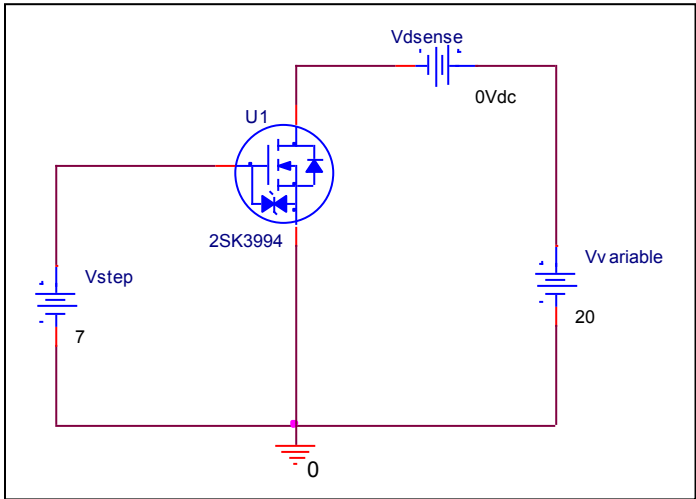
$I_D=10\text{ A}$, $V_{DD}=125\text{ V}$ $V_{GS}=0/10\text{ V}$	Measurement		Simulation		Error(%)
	ton	40.000 ns	40.452 ns	ns	

Output Characteristic

Circuit Simulation result

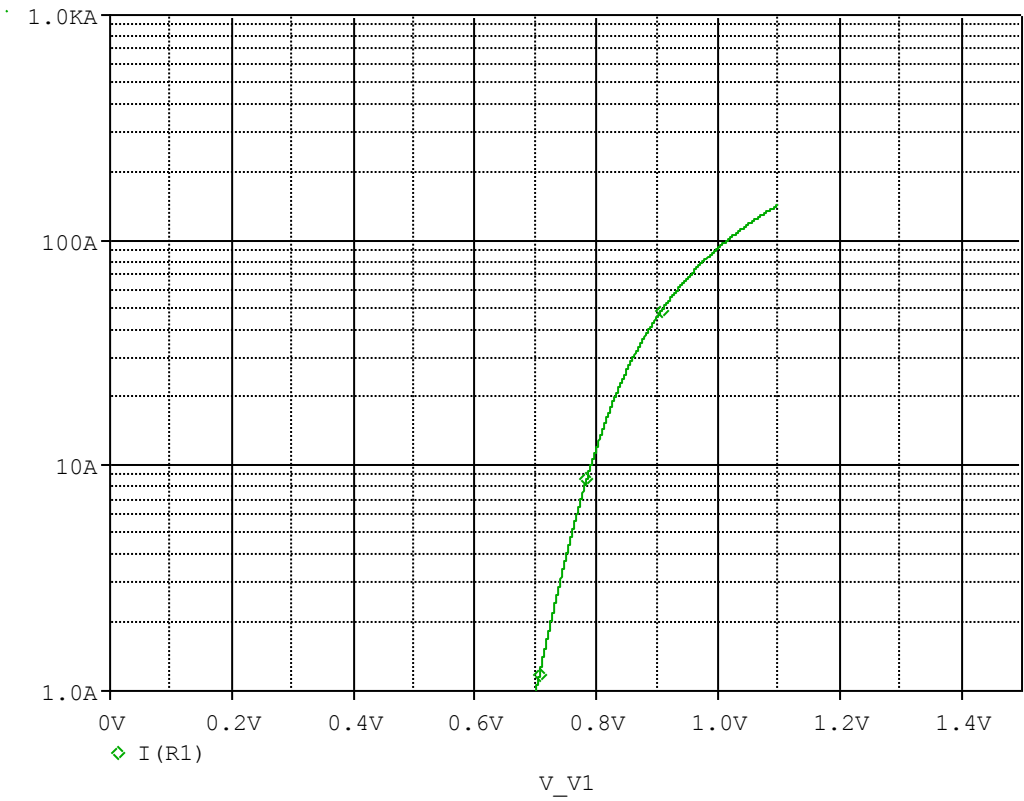


Evaluation circuit

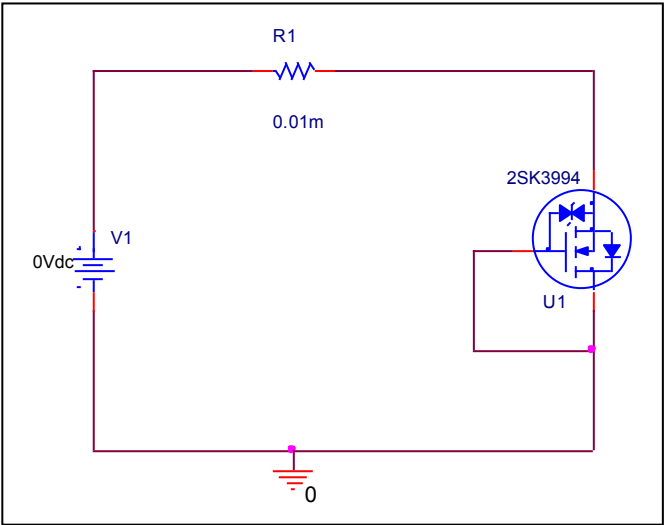


Forward Current Characteristic

Circuit Simulation Result

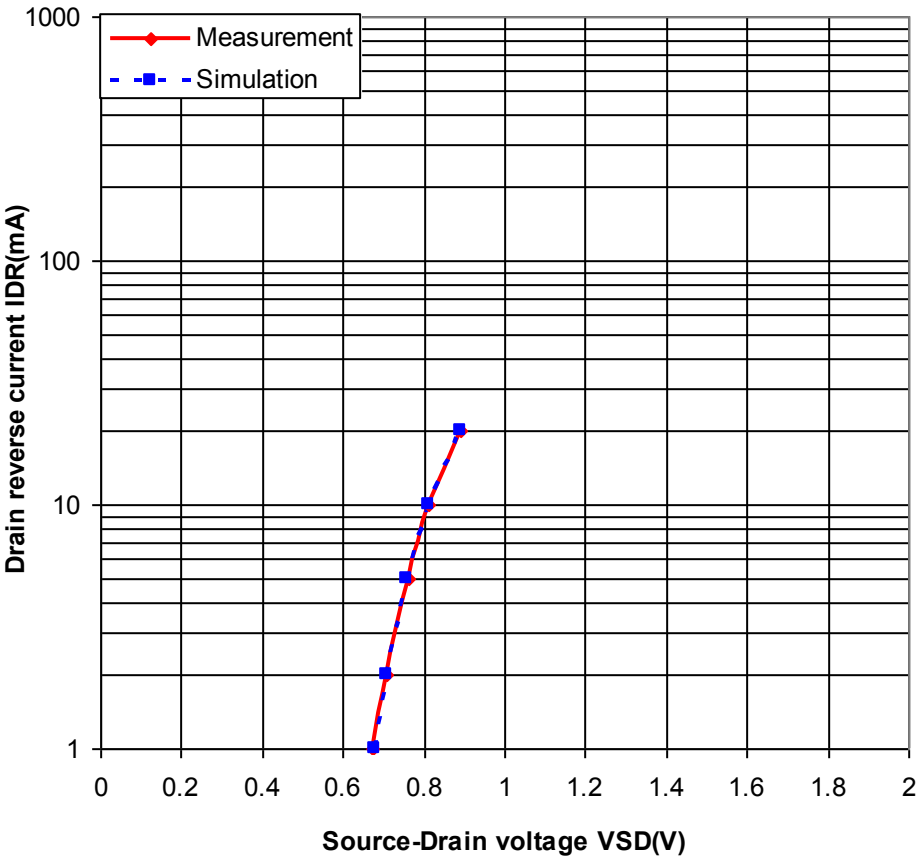


Evaluation Circuit



Comparison Graph

Circuit Simulation Result

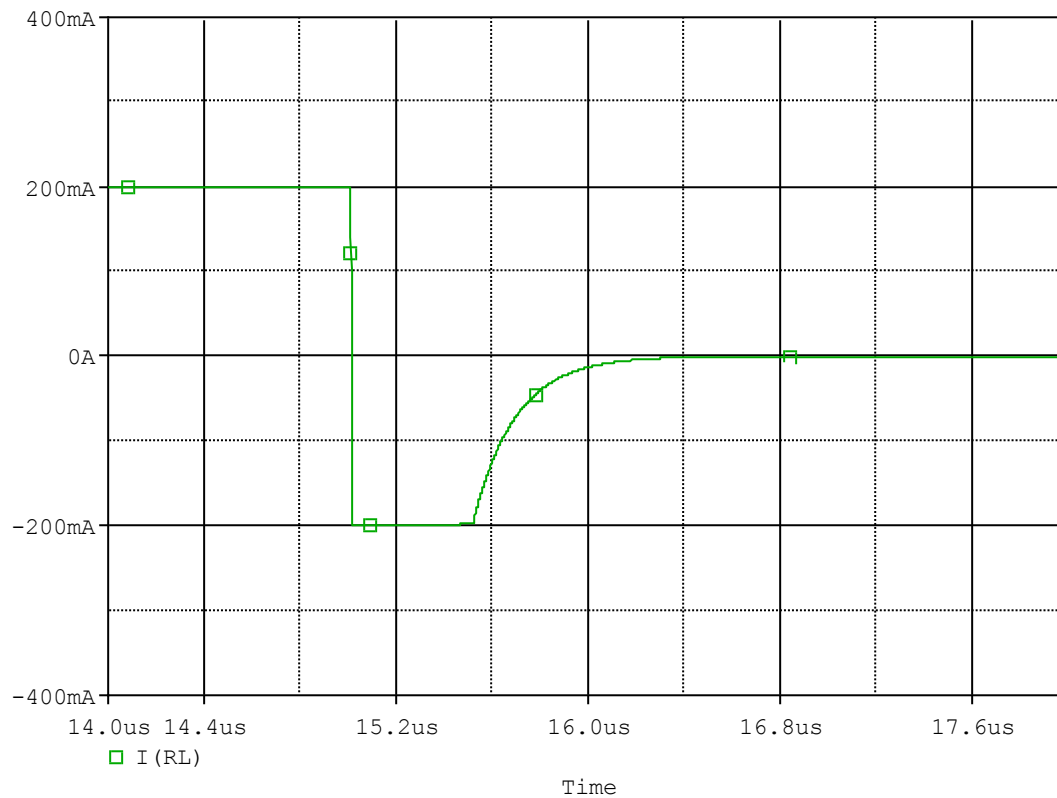


Simulation Result

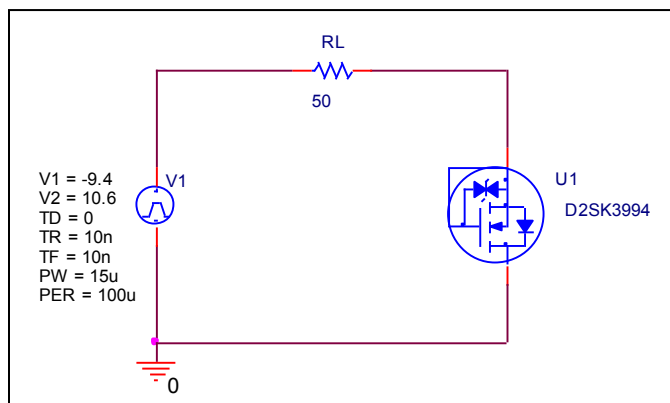
Ifwd(A)	VSD(V)		%Error
	Measurement	Simulation	
1	0.675	0.676	0.148
2	0.71	0.708	-0.282
5	0.76	0.759	-0.132
10	0.81	0.812	0.247
20	0.89	0.8896	-0.045

Reverse Recovery Characteristic

Circuit Simulation Result



Evaluation Circuit

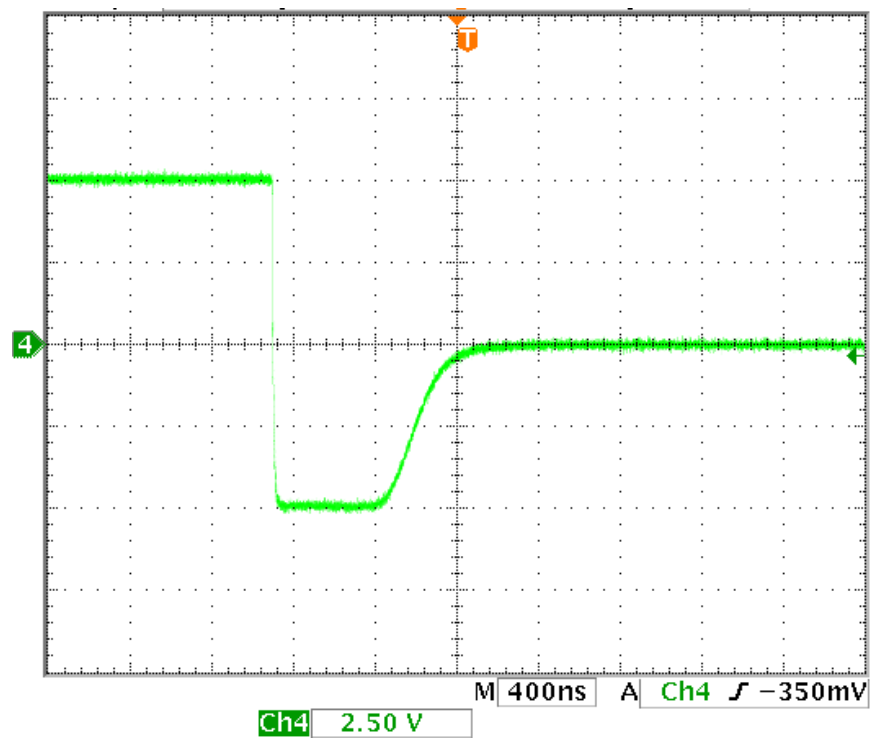


Compare Measurement vs. Simulation

	Measurement	Simulation	Error (%)
Trj(ns)	480	480.029	0.006
Trb(ns)	424	428.348	1.025
Trr(ns)	904	908.337	0.480

Reverse Recovery Characteristic

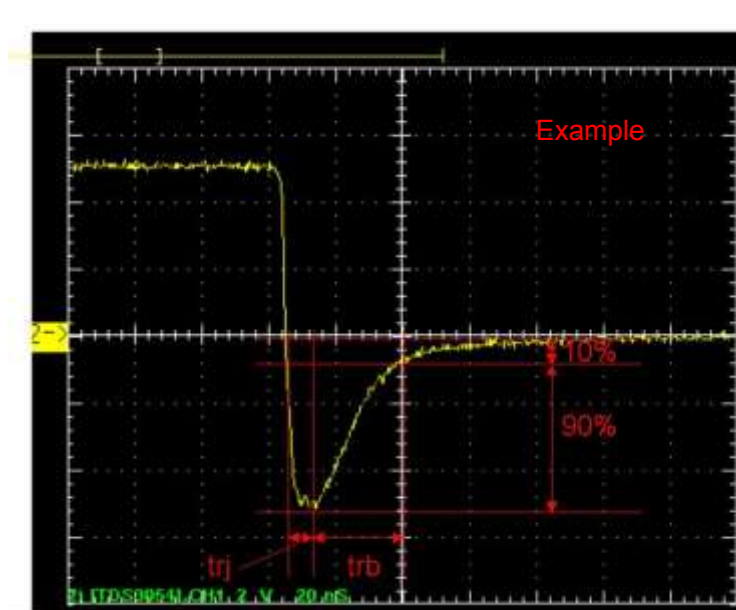
Reference



$T_{rr}=480(\text{ns})$

$T_{rb}=424(\text{ns})$

Conditions: $I_{fwd}=I_{rev}=0.2(\text{A})$, $R_I=50$

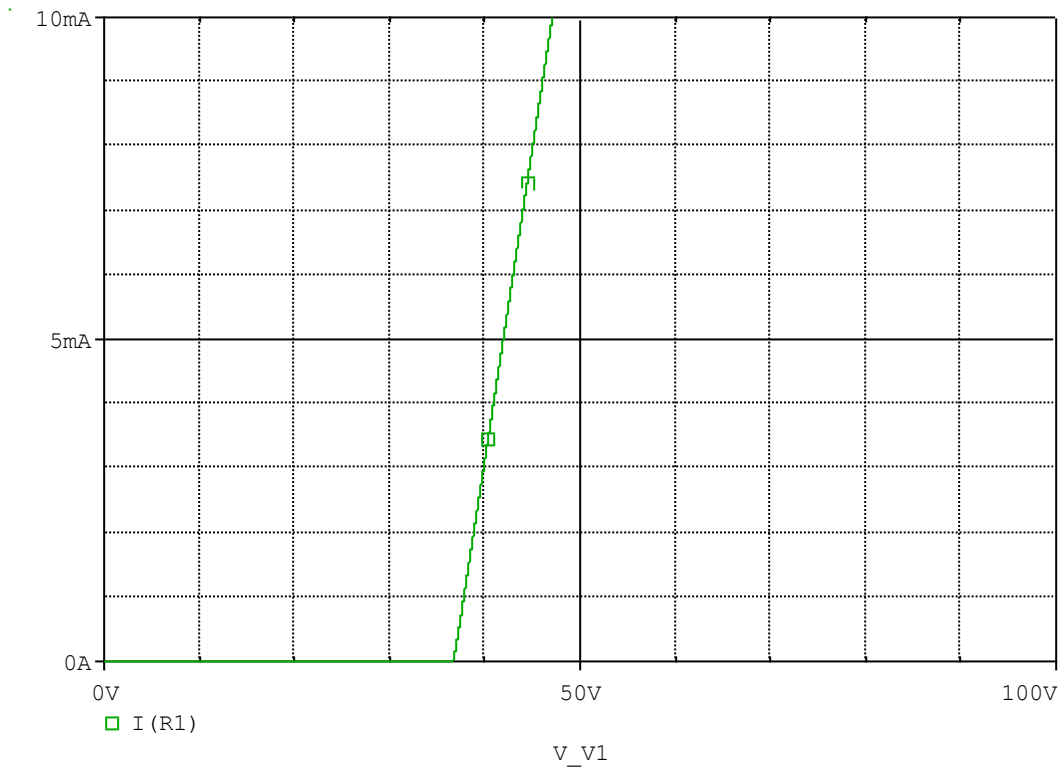


Relation between t_{rr} and t_{rb}

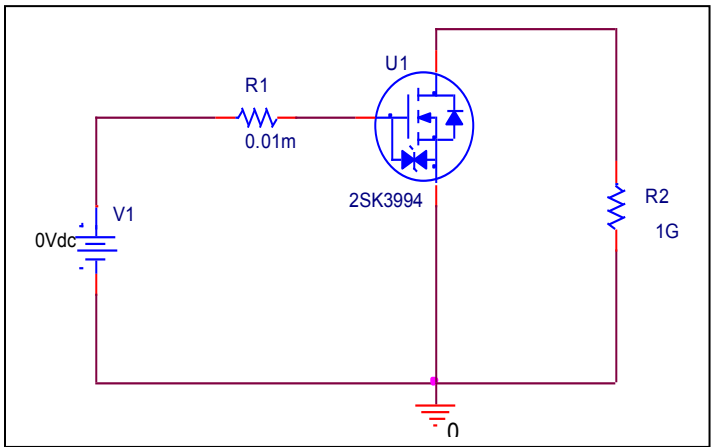
ESD PROTECTION DIODE

Zener Voltage Characteristic

Circuit Simulation Result



Evaluation Circuit



Zener Voltage Characteristic

Reference

